

Joint Journal Club IBM-Basel

Paper:

Quantum Dot-Based Parametric Amplifiers

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Quantum Dot-Based Parametric Amplifiers

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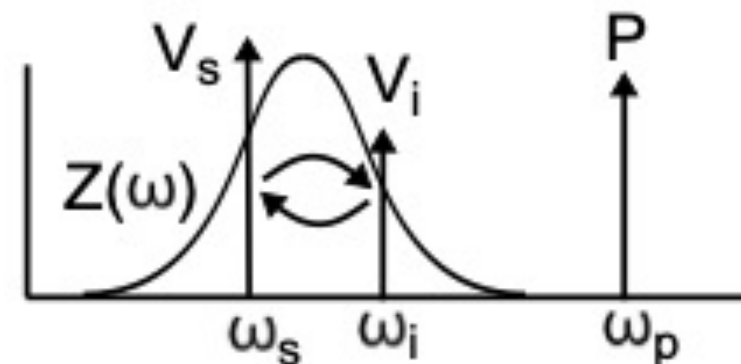
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(Dated: November 24, 2021)

- JPAs/TWPAs instrumental in enabling high fidelity readout of sc qubits and QDs
- Proposal 1: Quantum Capacitance alternative dissipationless non-linear element (vs. Josephson Inductance)
- Demonstration: Parametric amplification with a CMOS device achieving gains of -3 to +3 dB
- Proposal 2: Optimised design which could achieve gains comparable to JPAs

Parametric amplification

- Energy conversion between ‘signal’ mode (f_s) and ‘idler’ mode (f_i)
- Conversion mediated by pumping a non-linear element (f_p)



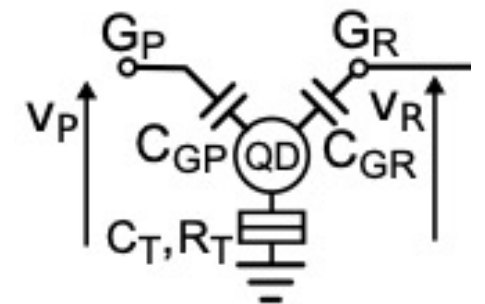
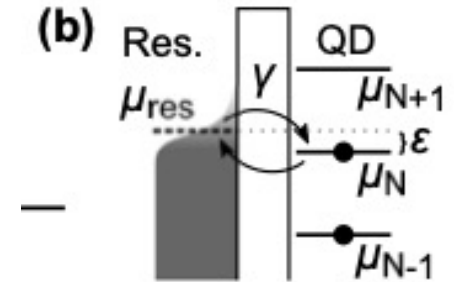
- “Standard” JJ based devices are challenging to integrate with spin qubits due to the heavy magnetic shielding required.
- Alternative non-linearities, e.g. based on kinetic inductance studied [24-26]

Quantum Capacitance as non-linear element

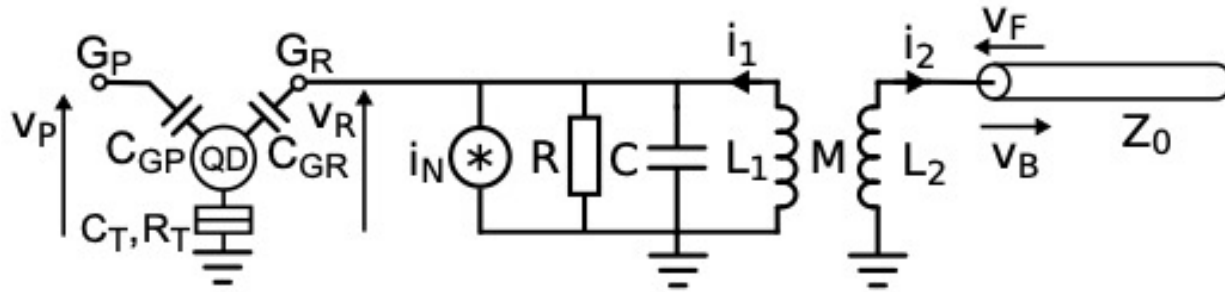
- Motivation: resilience against magnetic fields, compact, tight integration with spin qubits
- Differential capacitance seen by gate of QD
- For $f < \gamma$ and $T > \gamma$ tunneling to reservoir occurs adiabatically -> dissipationless quantum capacitance

$$C_Q = (e\alpha_R)^2 \frac{\partial P}{\partial \varepsilon} = \frac{(e\alpha_R)^2}{4k_B T} \frac{1}{\cosh^2(\varepsilon/2k_B T)}$$

- ‘variable’ capacitor with a quantum dot with 2 gates

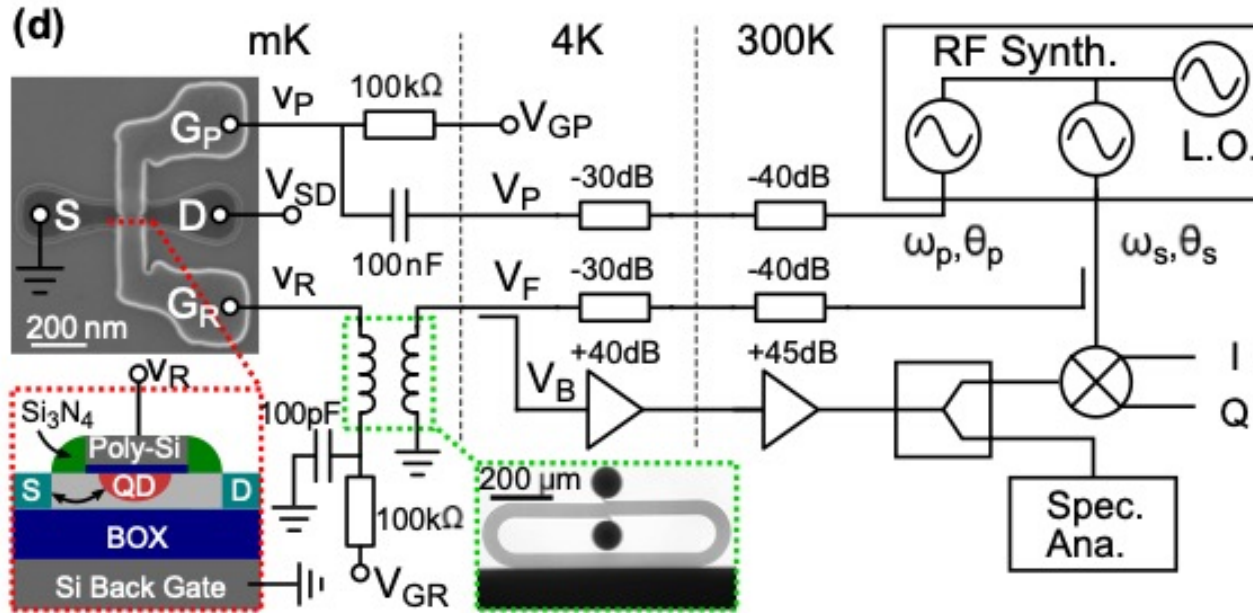


QDPA – the device



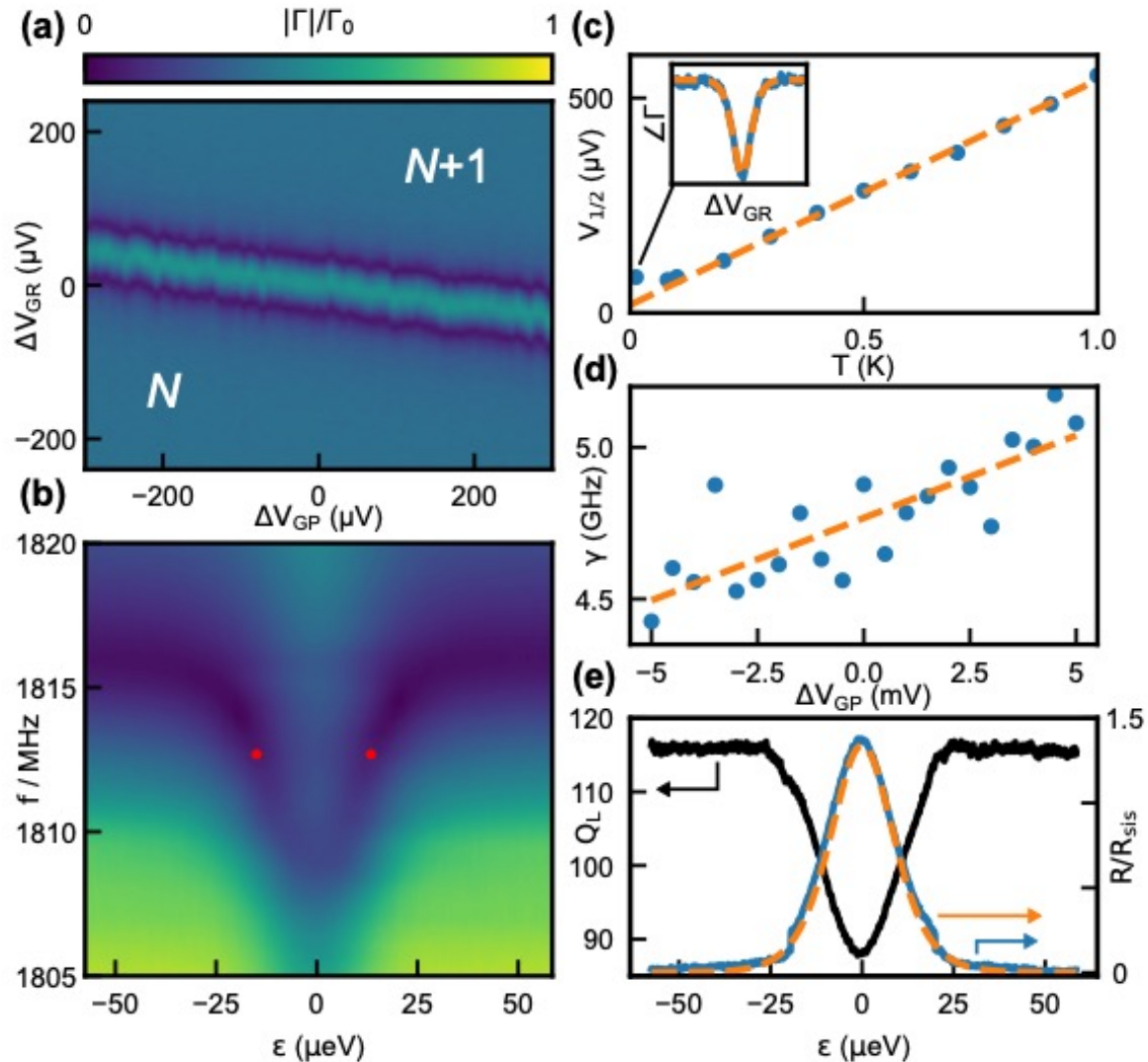
- Resonator attached to G_R
- Pump excitation applied to G_P

} QDPA



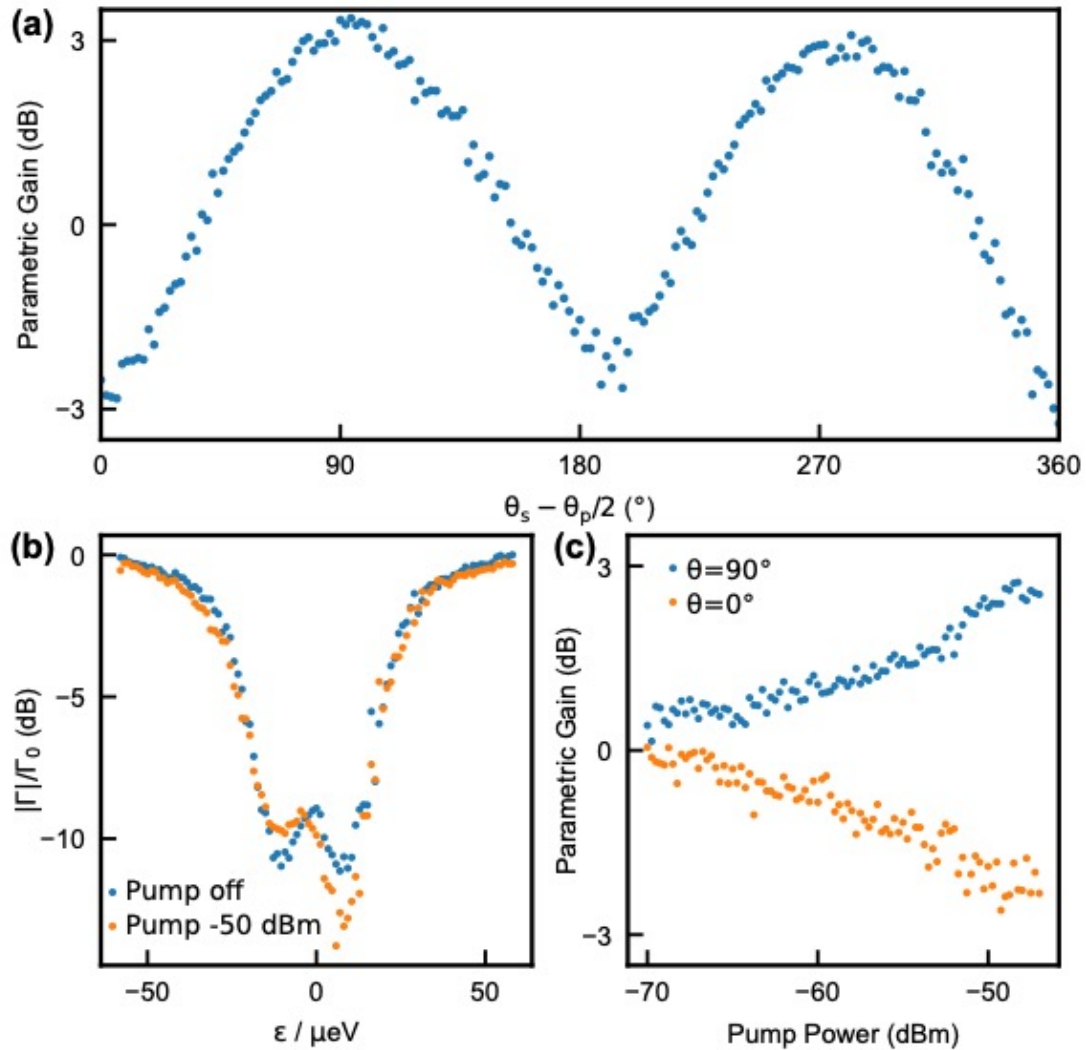
- Leti SOI device: 7 nm Si, 145 nm BOX
- Barrier: 34 nm
- Channel width: 70 nm
- Gate length: 60 nm
- Gate separation 40 nm
- $Z_r = 540 \text{ Ohm}$

Resonator Characterisation near dot-to-reservoir transition



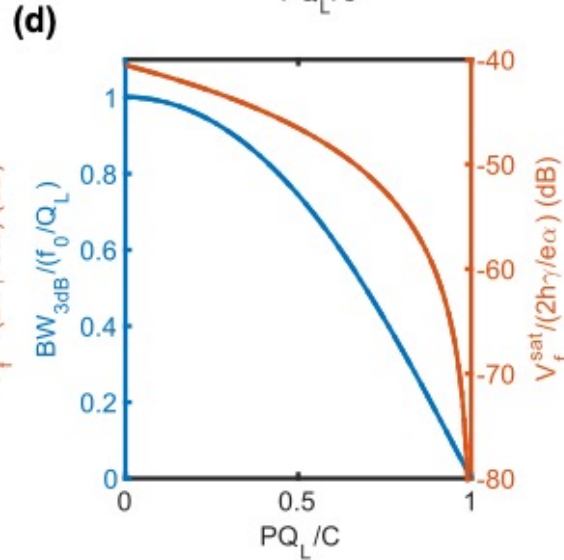
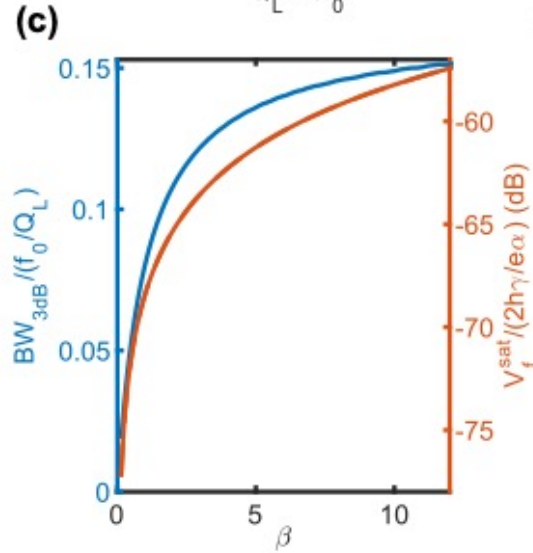
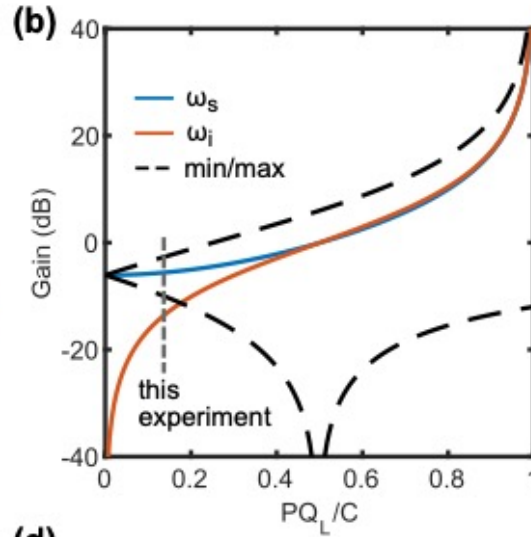
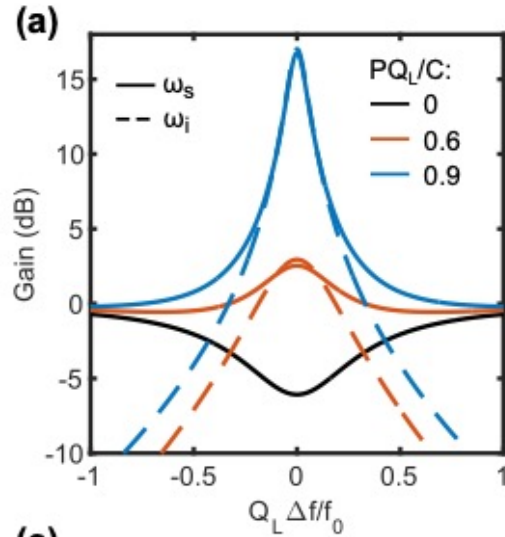
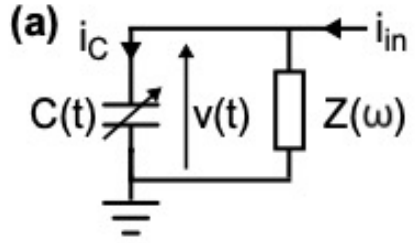
- No pumping
 - $C = 163$ fF
 - $C_Q = 0.93$ fF
 - $Q_i = 283$
 - At 12 mK transition is lifetime broadened
 - Tunnel rate ~ 4.77 GHz
-
- f_0 comparable to tunnel rate \rightarrow non-adiabatic tunneling contributions
 - Engineer tunnel rate to be $\gg f_0$

Parametric amplifier



- $f_p = 2f_s$
- Small variation of C_Q and dissipation limits gain

Model for better design



$$V_s = \frac{I_{in}Z(\omega_s)}{1 - \omega_s\omega_i |P|^2 Z(\omega_s)Z^*(\omega_i)}$$

$$V_i^* = \frac{j\omega_i P^* I_{in}Z(\omega_s)Z^*(\omega_i)}{1 - \omega_s\omega_i |P|^2 Z(\omega_s)Z^*(\omega_i)}$$